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Amended Patent Claims

- (original) A hard metal substrate body comprised of 1 a WC hard material phase and a binder phase of 3 to 25 mass % which 2 apart from at least one of the binder metals Fe, Co and/or Ni 3 contains up to 15 mass % of the binder phase dissolved dopant 4 selected from the group comprised of Al, Cr, V, Nb, Ta, Ti, Zr, Hf, 5 characterized in that the percentage proportion of all doping 6 agents in the hard metal is limited to a maximum of 4 mass % in 7 that the proportion of a cubic phase in the hard metal is less than 8 4 volume % and in that the binder metal content in a hard metal-9 substrate body boundary zone falls from up to 1 μ m, preferably up 10 to 0.5 μm to less than 0.5 times the binder content in the 11 12 substrate body interior.
 - 2. (original) The hard metal substrate body according to claim 1 characterized in that the concentration of the binder phase falls gradually toward the substrate body surface and the concentration of the dopant gradually increases in a corresponding manner.
 - 3. (currently amended) The hard metal substrate body according to claim 1 or 2 characterized in that the grain size of the WC is \leq 1.5 μ m whereby the WC fine hard metal (grain size \leq 0.8

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- 4 μ m) and/or with WC ultrafine grain hard metal (grain size ≤ 0.5
- 5 μ m), preferably contain Cr, V and/or Ta as dopant.
- 4. (original) The hard metal substrate body

 characterized in that at lest one layer is applied to the substrate

 body surface, the layer being comprised of a carbide, nitride

 and/or carbonitride of Ti, Zr and/or Hf and/or of Al₂O₃, HfO₂, ZrO₂,

 oxides, amorphous carbon, diamond, cubic boron nitride, carbon

 nitride (CN_x) or another compound of at least one of the elements

 B, C, N and/or O.
- 5. (currently amended) The hard metal substrate body according to claims 1 to 4 claim 1 characterized in that in the boundary zone close to the surface there is an enrichment with nitride or carbonitride of the metal dopant.

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6. (currently amended) A method of producing a hard metal substrate body according to one of claims 1 to one of claims $1 ext{ to } 5 ext{ claim } 1$ in which the starting mixture is preheated powder metallurgically is prepressed to a green body and then in an atmosphere of a furnace is heated and sintered, characterized in that in the heating phase, after reaching the eutectic, but no later than reaching the sintering temperature the vacuum or inert gas atmosphere is replaced with a N_2 atmosphere with a N_2 pressure of $\leq 10^5$ Pa and is maintained at least until the sintering temperature is reached.

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- (currently amended) The method of making a hard 11 7. metal substrate body according to one of claims 1 to 5 claim 1 in 12 which the starting mixture is powder metallurgically treated and is 13 pressed to a green body and finally heated in an atmosphere of a 14 furnace and sintered, characterized in that after finish sintering 15 or optionally in a final treatment above the eutectic temperature, 16 the sintered body is maintained in a N2 atmosphere under a pressure 17 (p) of 10^5 Pa 10^7 Pa for at least 10 minutes. 18
- 8. (currently amended) The method according to claim 6
 2 or 7 characterized in that the nitrogen atmosphere is established
 by introducing precursors that is N-containing gases whereby the
 nitrogen is formed in situ in the gas atmosphere.

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- 9. (currently amended) The method according to ene of claims 6 to 8 claim 6 characterized in that the body is heated up to 1250°C during the heating phase and this temperature is held for at least 20 minutes, preferably more than 1 hour, before the heating up is continued to the sintering temperature.
- 10. (currently amended) The method according to one of claims 6, 8 or 9 claim 6 characterized in that initially in the heating up phase at about 1200°C the previously existing vacuum is replaced by an inert gas atmosphere, preferably with a pressure of 10 Pa to 104 Pa and only upon reaching the sintering temperature is

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- a nitrogen containing atmosphere established with a higher
- 12 pressure, preferably $\geq 10^4$ Pa.
- 1 11. (currently amended) The method according to ene of claims 6 to 10 claim 6 characterized in that the heating up rate and the cooling down rate amounts to up to 10°C/min, preferably between 2°C/min and 5°C/min.

 1 12. (currently amended) The method according to ene of claims 6 to 11 claim 6 characterized in that the starting mixture
 - 12. (currently amended) The method according to ene of claims 6 to 11 claim 6 characterized in that the starting mixture contains up to 15 mass % of the binder phase additional carbides, nitrides, carbonitrides of the elements of Group IVa or VIa of the periodic system or Al or complex carbides, complex nitrides and/or complex carbonitrides of the form Ti₂AlC, Ti₂AlN, Cr₂AlN, Cr₂AlC.